

## ANKA-PDIFF: Polycrystalline X-ray Diffraction

### Technology:

*X-ray diffractometry*  
*Bulk and thin-film nano/microstructure analysis*  
*Chemical-crystallographic structural characterisation*

### Equipment:

- 3-circle powder diffractometer for large loads
- 4-circle single crystal diffractometer for low loads

### Category:

C. Particle Characterization in- and ex-situ

### Institute:

Karlsruhe Institute of Technology (KIT)

### Location:

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### Short technology description/Overview (approx 300 words):

Hard X-ray (6-21keV) synchrotron beamline for the structural investigation of polycrystalline materials under varying in-situ conditions and for high-resolution powder diffraction and residual-stress and texture measurements. The beamline is also well suited equipped for high-resolution scattering studies on single-crystals, epitaxial layers and bulk single-crystalline materials under ambient conditions. The experimental facilities consist essentially of a heavy duty 3-circle powder diffractometer with detectors and sample conditioning chambers and a second 4-circle kappa-goniostat optimised for high-resolution scattering experiments.

Typical applications of both experimental set-ups are:

- Real-time in-situ characterization of nanostructural & microstructural properties of metals and alloys,
- In-situ powder studies of crystallographic phase changes in bulk polycrystalline materials,
- High-resolution powder diffraction for chemical structure determination/characterization (e.g. pharmaceuticals)
- Residual-stress and texture analysis in functional polycrystalline thin films

### Main Features (Equipment Capabilities):

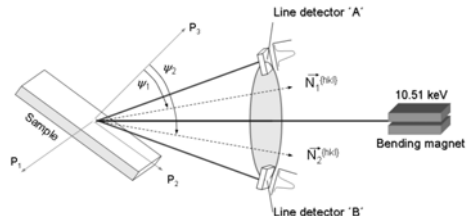
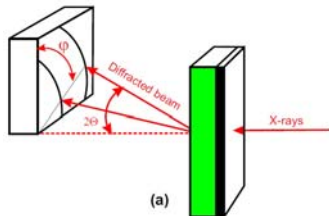
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| <ul style="list-style-type: none"> <li>▪ tuneable X-ray energy between 6 and 21keV (wavelength 2.1-0.62Å), focal spot size (fwhm) 0.6mm x 0.3mm, energy resolution (<math>\Delta E/E \approx 2 \times 10^{-4}</math> (at 10 keV)</li> <li>▪ 3-circle powder diffractometer (<math>2\theta_1, 2\theta_2, \theta</math>) with 2D and 1D detectors, Kappa-diffractometer with 3 sample orientation circles (<math>\Omega, K, \Phi</math>) and detector circle (<math>2\theta</math>) equipped with Ge111 or Si 111 crystal analyser</li> <li>▪ Spatial resolution approx. 100<math>\mu</math>m</li> </ul> | <ul style="list-style-type: none"> <li>▪ Diffraction experiments in either transmission or reflection between 77K &amp; 1300K</li> <li>▪ Various cells/sample holders for solid &amp; liquid samples</li> </ul> |
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### Limitations / constraints

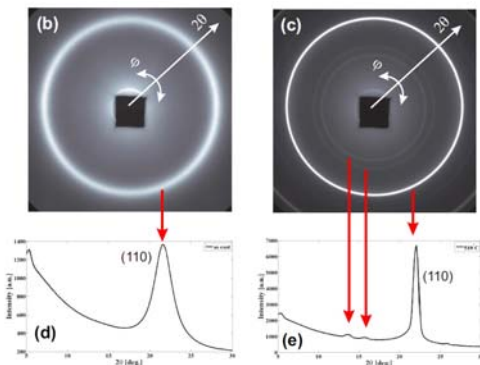
- Detection/Measuring limits: bulk sample quantities down to approx 5 mg, thin film samples down to a few 10's of nanometers thickness depending upon surface quality

- Time resolution for real-time investigations 0.1s to 10s depending on sample scattering power/quantity
- Some possibility of radiation damage depending on sample type (organic/biological samples more prone to X-ray damage)

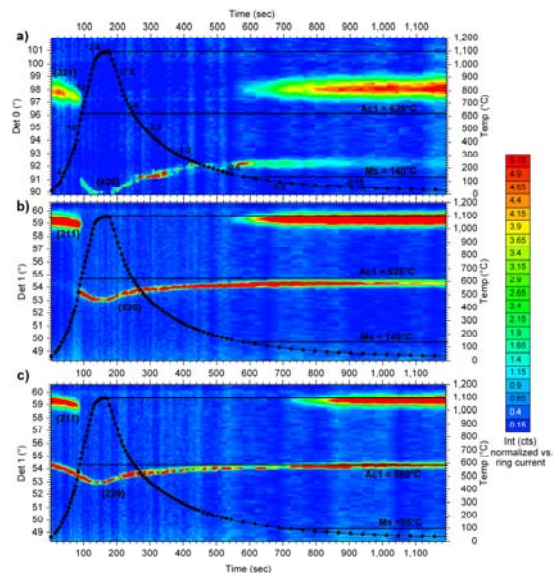
### Typical structures & designs



*Schematic view of single exposure set-up for fast in-situ strain analysis*



*Diffraction patterns of a metallic alloy in the glassy state (b, d) and after annealing at 500°C (c, e), showing the development of nanocrystalline structure (particle size approx. 10nm) with temperature.*



*Evolution of lattice parameter change in  $\alpha$ -Fe as a function of temperature: diffraction pattern sampling rate 1Hz.*

*Any further Information:*